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AMENDMENT

Claim Amendments

- 1. (canceled)
- 2. (canceled)
- 3. (canceled)
- 4. (canceled)
- 5. (canceled)
- 6. (canceled)
- 7. (canceled)
- 8. (canceled)
- 9. (canceled)
- 10. (original) A method of controlling the breakdown voltage of a snapback device, comprising

controlling doping levels of an isolation region by using a perforated mask during doping of the isolation region.

- 11. (original) A method of claim 10, further comprising annealing the device.
- 12. (original) A method of claim 10, further comprising exposing the device to one or more predefined elevated temperatures for predefined times.
- 13. (original) A method of increasing the breakdown voltage of a snapback device comprising

forming an isolation layer between active regions and substrate of the device, wherein the isolation layer includes forming spotted implants.

- 14. (original) A method of claim 13, wherein the spotted implants are formed by making use of a mask with intermittent openings.
- 15. (original) A method of claim 13, wherein the spotted implants are provided before one or both of an epitaxial layer being grown and high diffusion drive taking place.
- 16. (original) A method of claim 13, wherein the snapback device is an ESD protection device.
- 17. (original) A method of claim 13, further comprising annealing the device.

18. (original) A method of claim 13, further comprising exposing the device to one or

18. (original) A method of claim 13, further comprising exposing the device to one or more predefined elevated temperatures for predefined times.